

**UNIVERSITI TEKNOLOGI MARA**

**BEHAVIOUR OF BILAYER  
COMPOSITES TITANIUM DIOXIDE-  
ZINC OXIDE THIN FILMS RESISTIVE  
SWITCHING AND THEIR  
POTENTIAL FOR TACTILE SENSING  
DEVICE**

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**MSc**

May 2018

## ABSTRACT

This thesis covers the study on behaviour of bilayer composites metal oxide thin films resistive switching and their potential for tactile sensing application. In semiconductor, conduction mechanism is important to be analyzed for fundamental understanding on the device itself to further improve the device performance including the endurance and retention properties as well as identify the relation with resistive switching. Therefore in this work, the dominant conduction mechanisms for single and bilayer composites  $\text{TiO}_2$ -ZnO thin films resistive switching device were investigated. Furthermore to achieve resistive switching devices which responsive to the touch and pressure, the suitable material, fabrication properties and comprehensive measurement need to be identified. Thus, tactile sensor may require a flexible element of touch and pressure sensitive area in order to have the intense effect during measuring the sensor sensitivity with low temperature of heat treatments as the flexible element itself has very low thermal resistance. Also, this thesis was written to propose parameters and procedure for tactile measurement. As an initial step, bilayer composites thin films metal oxide with two different sequential structures  $\text{TiO}_2/\text{ZnO}$  and  $\text{ZnO}/\text{TiO}_2$  were fabricated on ITO/glass to finalize the optimal sequential structure to be deposited on ITO/PET for the flexural analysis. Fabrication processes involved were spin-coating, annealing and sputtering. The electrical and physical characterizations comprised I-V measurement with and without flexural effect, film thickness, surface morphology and cross-section. In the beginning, the characterizations were performed to investigate the optimal sequential structure which comes out with  $\text{TiO}_2/\text{ZnO}$  as the significant structure compared to  $\text{ZnO}/\text{TiO}_2$  by referring to the  $R_{\text{OFF}}/R_{\text{ON}}$  ratio and the consistency of resistive switching pinched hysteresis loop itself. Then the optimal sequential structure  $\text{TiO}_2/\text{ZnO}$  was fabricated on ITO/PET and different size of top electrode were deposited for the flexural I-V measurement preparation. Besides different size of top electrode, flexural I-V measurement with different bending angle was examine as well in order to study on the effect towards resistive switching behaviour. A clamping device was proposed in order to accomplish the flexural I-V measurement process to ensure the samples were bending evenly for precise results and error reduction. The investigation on the effect of different bending angle to resistive switching characteristics show slightly significant results compared to the assessment on different size of top electrode. Overall, the results suggested that composition of  $\text{TiO}_2$  and ZnO with appropriate fabrication parameters has the potential to act as a tactile sensor because it is responsive to the bending effect and due to the internal potential that was generated from the mechanical stress which was applied to the sample. For the performance of individual device, sample with  $0.3 \times 0.3$  cm metal contacts was considered as effective device due to the equality of resistance value at normal state yet it very responsive to the bending effect during convex and concave states.

## ACKNOWLEDGEMENT

First and foremost, Alhamdulillah and thanks to Allah S.W.T for all the blessings He had bestowed, the opportunity, and the greatest experience along the journey of my research. I would like to express my sincere gratitude to my supervisor Dr. Sukreen Hana Herman from Faculty of Electrical Engineering at Universiti Teknologi MARA, Shah Alam for the chance she had giving me, the continuous support, motivation, knowledge, guidance and her patience throughout the research. She consistently allowed this research to be my own work, but steered me in the right the direction whenever she thought I needed it. I could not imagine my journey of study without her outstanding supervision.

Beside my supervisor, I would like to thank my mentor Aznilinda Zainuddin from Faculty of Electrical Engineering at Universiti Teknologi MARA, Pasir Gudang for her passion and aspiration by encourage me to participate in few exhibition and competition as well as offering me the financial support from Malaysian Ministry of High Education (MOHE) under Research Acculturation Grant Scheme (RAGS). Additionally, this work is partially supported by MOHE under Niche Research Grant Scheme (NRGS) and Universiti Teknologi MARA (UiTM).

I would also like to acknowledge the staff from NANO-ElecTronic Centre (NET) especially Azwan, Suhaimi, Asrul and Danial for their assistance in the experimental work. Also my gratitude to Hayub Ta, Abul Khamis Ishak and Asnida, the staff in Faculty of Applied Sciences for their help and support in completing the characterization work.

My sincere thanks also go to my comrade, Rohanieza, Alhadi, Dalila Hazirah, and Azira Akma for the stimulating discussions, for the sleepless nights we were working together before deadlines, for the time you all spend to help in completing work lab and for all the fun we have had in the last three years. Not forget to other lab mates Najwa Ezira, Nurbaya, Siti Shafura, Farhaniza, Nur Shakina, Aimi Bazilah and Khairul Aimi for their motivation, kindness, joy and all the support during this study. Also, I thank my friend Hanisah for her advice and suggestion in finding the great supervisor at the beginning of my Master registration process.

Finally, I must express my very profound gratitude to my parents, Mohamat Kasim and , for my siblings, Nazirah, Nadhrah, Naim, Durratul, Syafaq, Hasbiyallah and Eitrah as well as to my beloved and supportive husband, Azhar for providing me with unfailing support and continuous encouragement throughout my years of study and through the process of researching and writing this thesis. This accomplishment would not have been possible without them. Thank you.

# TABLE OF CONTENTS

	<b>Page</b>
<b>CONFIRMATION BY PANEL OF EXAMINERS</b>	ii
<b>AUTHOR'S DECLARATION</b>	iii
<b>ABSTRACT</b>	iv
<b>ACKNOWLEDGEMENT</b>	v
<b>TABLE OF CONTENTS</b>	vi
<b>LIST OF TABLES</b>	x
<b>LIST OF FIGURES</b>	xiii
<b>LIST OF ABBREVIATIONS</b>	xxiii
<b>CHAPTER ONE: INTRODUCTION</b>	1
1.1 Research Background	1
1.2 Problem Statement	3
1.3 Objectives	4
1.4 Scope and Limitation of Work	4
1.5 Significant of Study	5
1.6 Organization of Thesis	6
<b>CHAPTER TWO: LITERATURE REVIEW</b>	8
2.1 Introduction	8
2.2 Resistive Switching Device	8
2.2.1 Classification of Resistive Switching Effect and Types of Switching Modes	9
2.2.2 Resistive Switching Conduction Mechanism	11
2.2.3 Fundamental of Memristive Device	18
2.3 Materials for Resistive Switching Device	23
2.3.1 Substrates	23

# CHAPTER ONE

## INTRODUCTION

### 1.1 RESEARCH BACKGROUND

Resistive switching denotes as a physical phenomenon where the resistance across a dielectric solid-state material is changed under the action of a strong electric field or current. Resistive switching is often tied to memristor which is known as the fourth basic passive circuit element which has exclusive properties that cannot be duplicated by any combination of other three elements (resistor, capacitor and inductor) [1]. It has a wide range of potential applications as it associates with memory element which has capability to memorize the last resistance it had after removal of applied bias.

Resistive switching device can be constructed from a simplest structure consists of insulator layer sandwiched by top and bottom metal electrode. Generally, this device can be defined by looking at the current-voltage characteristics having pinched hysteresis loop or “bow-ties” shape. Resistive switching can be classified into three (3) which are occurrence of thermal effect, electronic effect and ionic effect depending on the material that were used for electrodes and the dielectric. The dielectric part can be made using organic compound [2] and several materials but most of researcher extensively selected titanium dioxide ( $\text{TiO}_2$ ) as this transition metal oxide has unique properties [3]–[7] which are highly resistivity in its pure state, wide band gap, compatible with standard complementary metal-oxide-semiconductor (CMOS) technology [5], [7] and the most important is it has potential to eliminate the necessity of electroforming process in resistive switching device. Moreover, because of its structural and optical properties,  $\text{TiO}_2$  has been used in variety of applications such as in solar cell, gas sensor, photo-catalysis and biomedical applications [8]–[11]. Other than  $\text{TiO}_2$ , there are several types of materials that have been considered for resistive switching device study such as silicon dioxide ( $\text{SiO}_2$ ) [12], zinc oxide ( $\text{ZnO}$ ) [13]–[17], nickel oxide ( $\text{NiO}$ ) [18] and so forth.